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APPLICANTS	×								
Jae Chang Jung	g, Ichon-shi, KOREA, R	KEPUBLI	C OF;						
Keun Kyu Kong, Ichon-shi, KOREA, REPUBLIC OF; Min Ho Jung, Ichon-shi, KOREA, REPUBLIC OF;Geun Su Lee, Ichon-shi, KOREA, REPUBLIC OF; Ki Ho Baik, Ichon-shi, KOREA, REPUBLIC OF;									
** CONTINUING DATA **********************************									
** FOREIGN APPLICATIONS ************************************									
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Foreign Priority claimed 35 USC 119 (a-d) conditions met Verified and Acknowledged Exam	AT TO ALL	er JL itials	STATE OR COUNTRY KOREA, REPUBLIC OF	DRAV	EETS WING 2	TOTA CLAIM 19	MS	INDEPENDENT CLAIMS 2	
ADDRESS 20350 TOWNSEND AND TO TWO EMBARCADERO EIGHTH FLOOR SAN FRANCISCO, C. 94111-3834		[/] , LLP							
TITLE Cross-linking monome	ers for photoresist, and p	process	for preparing r	hotores	sist polym	iers usi	ing the	same	
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FILING FEE	FEES: Authority has been given in Paper No to charge/credit DEPOSIT ACCOUNT No for following:	1.16 Fees (Filing) 1.17 Fees (Processing Ext. of time)		
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